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The example of an applied circuit or combination with other equipment shown herein indicates characteristics and performance of a semiconductor-applied product.

The Company shall assume no responsibility for any problem involving a patent caused when applying the descriptions in the example.

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In developing power MOS FETs, Hitachi took note of the outstanding characteristics of small signal MOS FETs for high frequency amplification in TV tuners and FM tuners. After intensive research, we perfected high-output MOS FETs and introduced them as commercial products.

Hitachi's power MOS FETs have the line-up shown in Table 1-1. Each pair consists of an N channel type and a P-channel type, which have complementary characteristics.

- MOS FETs have the following advantages:
- Require a very low driving power as they are voltagecontrolled devices.

- Free from current concentration, and hence have enormous resistance to destruction.
- Good frequency response and high switching speed due to absence of carrier storage effect.

These advantages make for the outstanding characteristics of power amplification devices. On the other hand, it is difficult to provide MOS FETs with the high voltage and high current characteristics required of power amplifiers. Hitachi succeeded in imparting these characteristics to MOS FETs by the method described in a later section of this application note.

Туре				VDSX (V)		110-50
N-Channel	P-Channel	Outline	ID (A)	(VDSS (V))	Peh * (W)	price
 25K138	2SJ48		201 7 2	120	100	
2 SK 1 3 4/H	2SJ49/H	JEDEC: TO-3 EIAJ: TC-3, TB-3	7	140	100	\$5-10
2 SK 1 3 5/H	2 S J 5 0 / (H)		7	160	100	\$ 6.34
2 SK 1 7 5/H	2SJ 55 / (fi)		8	180	125	
2 SK 1 7 6/(H)	2 S J 5 6 / (H)		8	200	125	-3736 \$
2 SK 2 2 0 🕀	-		8	(160)	100	
2 SK 2 2 1 H	_	· · ·	8	(200)	100	· · · · · ·
2 SK 2 2 5	2SJ 81	НРАК	7	120	100	
2 SK 2 2 6	2 S J 8 2	e je	7	140	100	•
2 SK 2 2 7	2 SJ 8 3		7	160	100	
2 SK 2 1 3	2 S J 7 6	JEDEC: TO-220AB EIAJ: SC-46	0.5	140	30	× .
2 SK 2 1 4	2 S J 7 7		0.5	160	30	
2 SK 2 1 5	2 SJ 7 8		0.5	180	30	
2 SK 2 1 6	2 SJ 7 9	e î î î	0.5	200	30	SK216 \$ 2,06

MOS FETTS

Table 1-1 Series and Maximum Ratings of Power MOS FET

* Value at Tc=25*C

91.8200

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A problem encountered in commercializing a MOS FET for power applications is the required high-voltage and high-current characteristics.

-(0 01

The high-voltage characteristics will be explained with reference to the cross section of a power MOS FET in Fig. 2-1. The gate oxide layer (SiO_2) of an FET withstands a voltage of 20 ~ 30 V at best. As shown in Fig. 2-1, a power MOS FET has an offset-gate structure in which the drain and gate are separated. And between the separated gate and drain, a dopant is implanted by ion implantation, to create an ion-implanted layer so as to ease electric field concentration. Moreover, to prevent electric field concentration near the gate, a field plate is provided. In this way, destruction of the gate oxide layer is avoided and high voltage durability is achieved.

High current characteristics are obtained by a combstructure of source-drain pattern. Fig. 2-2 shows the equivalent circuit of N channel device, r_g is the AC resistance of gate electrode, and C_{gs} is the equivalent capacitance of gate oxide layer.

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Operational Features and Reliability

3.1 Output Characteristics

Figs. 3-1 and 3-2 show the output characteristics of the \dots -channel MOS FET 2SK135. Whereas in a small signal MOS FET the forward transconductance y_{fs} is 10 ~ 20 mS (milli-siemens) at best, in a power MOS FET it is 1.0 S. Also, as obvious from Figs. 3-1 and 3-2, 2SK135 has pentode characteristics and an excellent linearity of y_{fs} in relation to I_D .

P channel MOS FETs also have similar characteristics. P channel and N channel types have complementary characteristics.





3.2 Frequency Response Characteristics

Fig. 3-3 shows the frequency response characteristics of a power MOS FET in the source common state. The cut-off frequency of an N channel device is about 3 MHz. The frequency response is dependent on the gate resistance and input capacitance shown in Fig. 2-2.

In the output stage of an audio amplifier, a source follower is used. The frequency response of the source follower is 10 times greater than in the case of source common because, as shown in Fig. 3-4, input capacitance is reduced by the mirror effect. The frequency response of a power MOS FET is more than one order better than that of a bipolar transistor.



Fig.3-3 Frequency Response Characteristics of lyfsl (Source Common)





3. Operational Features and Reliability-

3.3 Switching Characteristics

A power MOS FET has no minority carrier storage and can switch a 2 A current at speed of $10 \sim 30$ ns. This switching speed is $50 \sim 100$ times as high as that of a bipolar transistor and represents a great advantage when a power MOS FET is applied to various high-speed largepower switching circuits, such as described later in this application note.

Fig. 3-5 shows current waveforms where a power MOS FET is applied to a class-B amplifier stage of an audio amplifier. The waveform is ideal for a power MOS FET which, unlike a bipolar transistor, has no storage time.



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3.4 Area of Safe Operation (A.S.O.)

Since a power amplifier device is operated at high voltage and high current levels, it must be designed to withstand electrical destruction. A power MOS FET basically takes full advantage of its excellent thermal stability, so that a much wider area of safe operation can be guaranteed for it than for a bipolar transistor.

Fig. 3-6 shows the areas of safe operation for DC operation and pulse operation. Since a power MOS FET is free of secondary breakdown in the high voltage region, the guaranteed area of safe operation is equal to the range of thermal limitation.



Fig.3-6 Area of Safe Operation (2SK135/2SJ50)

3.5 Temperature Characteristics

Fig. 3-7 shows the transfer characteristics of power MOS FETs. In the high current area, the temperature coefficient is negative and current concentration does not occur, so that a wide area of safe operation is provided and destruction by thermal runaway is largely prevented. Since the transfer characteristics of power MOS FETs are of the enhancement type, as in the case of bipolar transistors, power MOS FETs do not require a complex biasing circuit as depletion type FETs do.

In power MOS FETs, the temperature coefficient of drain current becomes zero around $I_D = 100$ mA.

By taking advantage of these temperature characteristics, the power MOS FET circuit can dispense with an idling current compensation circuit and feedback resistance for current stabilization, which are required in the bipolar transistor circuit as shown in Fig. 3-8. Hence, a simple circuitry as shown in Fig. 3-9 is obtained.







 O + Vcc

 Rs

 Rs

 P-Channel

 Signal

 Source

 Fig.3-9

 Audio Output Circuit using of

 Power MOS FET

3.6 Reliability

High quality and high reliability are achieved in power MOS FETs by applying the process technology and quality control established for MOS LSI and bipolar power transistors.

In order that you may use Hitachi's power MOS FETs with high reliability, explanation will be given by referring to reliability test data.

(1) Reliability design and process features

The chip structure of a power MOS FET is illustrated in Fig. 3-10. In order to achieve high voltage durability and high output characteristics, the following design and process considerations are given:

Chip structure

To ease electric field concentration between source and drain, a low-concentration dopant is implanted by ion implantation, to form an offset gate structure. Further, by providing a source field plate, high voltage durability is achieved.

• Chip fabrication process

Since micropatterns and integration degrees similar to those of LSI are used, basic process technologies established for MOS LSI, such as surface passivation and electrode formation, are applied.





3. Operational Features and Reliability-

(2)	Reliability data	
•	Failure criteria	
)	•	

Items for reliability tests and failure criteria are presented in Table 3-1.

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Table 3-1 Failure Criteria

1	Sumbol	Failure Cri		
	Symbol	Lower	Upper	
Breakdown Voltage	V(BR)DSX ±V(BR)GSS	L × 0.8	-	v
Leak Current	I _{DSX} ±I _{GSS}	·	U × 2	μA
Cut-off Voltage	V _{GS (off)}	0	U × 1.2	v
Saturation Voltage	V _{DS (sat)}	-	U × 1.2	۷.
Saturation Voltage Ratio	△V _{DS} (sat)	-30	+ 30	%
Forward Transfer Admittance	y f s	L × 0.8	U × 1.2	S
Forward Transfer Admittance Ratio	≏lyfsj	- 30	+ 30	%

(Note) U: Upper Limit After the Test L: Lower Limit After the Test

Reliability test results

The results of reliability tests on complementary pair wer MOS FETs 2SK135/2SJ50 are given in Table 3-2. Table 3-3 shows the temporal changes of major parameters in device life tests.

Table 3-2 Test Results

	· · · · · · · · · · · · · · · · · · ·	N-C	hannel (2SK1	35)	P-Channel (2SJ50)			
It em	Test Conditions	Sample Number (pcs)	Testing Time (hr)	Failure (pcs)	Sample Number (pcs)	Testing Time (hr)	Failure (pcs)	
Operating Life Test	Ta=25°C, Pch=27W, $V_{DS}=80V$ Heat Sink $\theta_f = 3°C/W (T_j=150°C)$	80	2,000	0	100	2,000	0	
High Temperature Re- verse Bias Test	Ta=150°C, V _{DSX} =160V, V _{GS} =-10V	125	2,000	0	140	2,000	0	
Humidity Test	Ta=80°C, RH≧ 90%	77	2,000	0	77	2,000	0	
Low Temperature Storage Test	T₂=-55°C	45	2,000	0	45	2,000	0	
Thermal Fatigue Test	△T _C =90°C, Tjmax=150°C ON: 1 minute, OFF: 1.5 minutes	50	10k cycles	0.	50	10k cycles	0	
Temperature Cycle Test	-55~+150°C, 30 minutes each	730	10 cycles	0	580	10 cycles	0	
Resistance to Solder- ing Heat Test	260°C, 10 seconds	22	-	0	22	_	0	
Drop Shock Test	1500G, 0.5ms, XYZ(3 times each)	77		0	77	-	0	
Vibration Fatigue Test	60Hz, 20G, XYZ(32 hours each)	38		0	38	_	0	
Vibration-Variable Frequency Test	100~2000Hz, 20G, cycle time 4 min. XYZ (3 times each)	38	_	0	38	-	0	
Constant Acceleration Test	20000G, XYZ(1 minute each)	38	-	0	38	-	0	
Capability Against Elec- trostatic Discharge Test	C=200pF, V=300V forward and reverse polarity between G-S (one time each)	100	_	0	100	-	0	

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Table 3-3 Changes of Major Parameters



وأودين يتعالجه 14.000 201 - 5 119. 1.10 Ξ, 1.1.14 · :••*• 1. 1. 1. 17 to 1. 1 13 20 3. مراء المندط د : • '¥∶' 1. 18 March at any anator of a + 2 GE • " a series <u>per la constant</u> con AC to tack or the light in the - -**.** . s and some more a r tala platena do . . 5.12

Design of High Power Application (Parallel Operation)

As stated in section 3.5, the negative temperature coefficient of drain current and the high input impedance of power MOS FETs enable parallel operation to be performed with an extremely simple circuit.

In the parallel operation of bipolar power transistors, scattering of V_{BE} and h_{FE} characteristics causes an unbalance in collector current and, as a result, large current transistors generate high heat, which in turn further increases current flow; this may lead to thermal runaway. In a power MOS FET there is no possibility of thermal runaway because the drain current has a negative thermal coefficient.

Fig. 4-1 shows a triple connection circuit. Forward ransfer admittance is three times as large as when a single device is used. In Figs. 4-2 and 4-3, this is expressed in waveform on a curve tracer. A current of about 20 A can be controlled by several volts of gate voltage.







Fig.4-2 Output Characteristics in Triple Connection Circuit(1)



Fig.4-3 Output Characteristics in Triple Connection Circuit(2)

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4.2 Design of High Breakdown Voltage Application (Series Operation)

(1) Totem pole connection

Fig. 4.4 shows a basic "totem pole" circuit, in which power MOS FETs are connected in series. This circuit has been used extensively as a saturated logic circuit, the basic circuitry for TTL IC. Operation of this circuit will be explained.

When no bias is applied to Q_1 , Q_1 is cut off because power MOS FETs have enhancement type transfer characteristics; thus the following relationships hold;

 $V_{G1} = 0, I_D = 0$





Fig.4-4 Basic Totem Pole Circuit

where V_{th2} is the threshold voltage of Q_2 . Generally, $V_{th2} \ll V_{DD}$. Therefore $V_O \simeq \frac{1}{2} V_{DD}$.

And the voltage applied to Q_1 and Q_2 will be about $\frac{1}{2}V_{DD}$. Next, let us consider a transient state. When the gate bias

of Q_1 is increased gradually from zero, Q_1 will become conductive and so will Q_2 at the same time. If load resistance Z_L is inserted between V_{DD} and drain of Q_2 , drain voltage will be $V_D = V_{DD} - Z_L \cdot I_D$ and V_O (=¹/₂ $V_D - V_{GS2}$) will gradually decrease.

If V_{DD} has a much larger value than V_{GS2} and Q_2 is driven up to the saturation region, then the characteristics of an equivalent MOS FET would be dependent on Q_1 .

Generally, when devices are operated in series, voltage unbalance due to switching time difference presents a problem. This problem is overcome in power MOS FETs because switching time can be made as short as several tens of nanoseconds.

Figs. 4-5 and 4-6 show breakdown and output characteristics where a single device is used. When this device is used in the circuit shown in Fig. 4-4, the breakdown and output characteristics would be as shown is Figs. 4-7 and 100 (Y) - Huand U -







4-8. Breakdown voltage in Fig. 4-7 is twice as high as in Fig.
4-5. The disadvantage is that on-resistance is also doubled,
as is obvious from Figs. 4-8 and 4-6. A method of improving on-resistance is described in the following section.
(2) How to reduce on-resistance in basic circuit

On-resistance (or saturation voltage) can be reduced by performing level shift of the Q_2 gate potential in the positive direction. This can be accomplished, for instance, by the methods shown in Fig. 4-9. Fig. 4-10 shows the output characteristics for a case where the gate is levelshifted to the positive side. (14 V is the maximum allowable gate-to-source voltage.)

In the circuit shown in Fig. 4-9, as in the basic circuit, the equivalent drain to source breakdown voltage is twice as high as when a single device is used.





4. Application Hints-





(3) Improvement of high frequency characteristics in totem y pole connection

When the circuit shown in Fig. 4-4 is modified for a source follower, because of the different operation of Q_1 and Q_2 , a phase differential occurs under the influence of the power MOS FET input capacitance (about 500 pF for 2SK134, 600 pF for 25J49, f=1 MHz). As a result, characteristics worsen, as high frequency gain drops and phase shift increases.

This is expressed in Fig. 4-11. The equivalent circuit with passive devices alone is represented in Fig. 4-12.

It has been verified experimentally that the phase differential of V_{O1} and V_{O2} can be eliminated and driving in the same phase can be achieved by equalizing C_g with C_{in2} and that phase shift as 100 kHz can be limited within -90 degrees.











5.1 A.S.O. Limitation of Power MOS FETs

The most basic and important characteristic required of power device is a high breakdown strength. As stated, breakdown strength is closely related to other characteristics. Power MOS FETs have a thermal durability close to their thermal limitation, which is dependent on package configuration.

DELL

Fig. 5-1 shows breakdown points of power MOS FETs in relation to those of bipolar transistor. In Fig. 5-1, the curves marked 50, 100, 200, and 500 (W) are thermal limitation curves. Breakdown points of actual devices are along these curves.



5.2 Thermal Mapping of Chip Surface Under Power Application

Current flowing in power MOS FETs does not concentrate locally but flows uniformly in the silicon chip.

Fig. 5-2 shows the thermal mapping of chip surfaces under power application for a power MOS FET and conventional bipolar transistors. Whereas the thermal mapping in the power MOS FET is uniform, a hot spot is generated in the bipolar transistor shown in Fig. 5-2 (c) although the power applied is one-half that applied to the power MOS FET.



Fig.5-2 Thermal Mapping of Power MOS FET and Bipolar Transistor with an Infrared Scanner





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6. Handling Brecaulikon

Handling precautions and simple checking methods will be described for the benefit of those who use Hitachi's power MOS FETs.

I handled improperly, power MOS FETs cannot display their excellent performance described in the foregoing. Not only that. Improper use can lead to destruction of the devices.

Also, it is necessary to take into consideration the abnormal oscillation due to high gain, high input impedance, and excellent high frequency characteristics, which are some of the features of power MOS FETs.

By observing these precautions, circuits can be designed with outstanding performance that cannot be expected from using conventional power devices,

6.1 Pin Arrangement

As shown Fig. 6-1, the pin arrangement is different from that of ordinary transistors. (The source is the case.)





6.2 Measurement of Breakdown Voltage VDSX and VGSS

Avoid measuring V_{DSX} (drain-to-source breakdown voltage) and V_{GSS} (gate-to-source breakdown voltage). At breakdown, negative resistance characteristics are generated, leading to oscillation and destruction.

6.3 Observation of ID-VDS Characteristics

- When the I_D - V_{DS} characteristics (source common output characteristics) are observed, oscillation may be caused depending on the type of curve tracer used (input capacity/resistance differs). This can lead to destruction of the device. Oscillation can be prevented effectively by connecting a series resistance of about 10 k Ω to the gate.
- When drawing a I_D-V_{DS} curve on an X-Y recorder, also, prevent oscillation by connecting a series resistance of about 10 kΩ to the gate or by inserting a capacitor of about 0.5 µF between the gate and source.

6.4 Circuit Experiments

- In performing circuit experiments, it is recommended that you connect a resistance of 100 $\Omega \sim 2 k\Omega$ to the gate in series, to prevent oscillation, until you get used to handling.
- In using the device as a source follower, it is recommended that oscillation be prevented by inserting a 100 μ F capacitor between the V_{DD} line near the drain and ground.

(Note)

The precautions described in 6.2 through 6.4 above are required because of the excellent high frequency characteristics and transfer characteristics of power MOS FETs.

6. Handling Precautions

6.5 **Checking with Circuit Tester**

Here are some simple ways to check power MOS FETs with a circuit tester to see that they operate normally.

٠ Gate-to-source

Check and make sure there is no gate-to-source conduction in either direction.

Drian-to-source (for N-channel devices)

Set the circuit tester for resistance measurement (x 1 Ω). As in Fig. 6-2 (a), connect the plus lead to the source, contact the minus lead to the gate and then connect it to the drain. Since the gate is then charged positively (forward basing), the pointer will flip to indicate conduction.

Next, as in Fig. 6-2 (b), connect the minus lead to the source and after contacting the plus lead to the gate (whereupon the gate will be charged negatively), connect e minus lead to the drain and the plus lead to the source. The pointer will not flip indicating a cut-off state.

As long as the above results are obtained, the device may be expected to perform normally.

For P channel devices, checking can be performed similarly simply by reversing the plus and minus leads.



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	Fun	ction	Application				
)	Wide band linea	r amplification	 Audio power amplifiers* Deflection circuits for CRT displays Medium wave - high frequency band modulators, transmitters* Citizen band transmitters 				
	Power switching	g	 DC-AC inverters AC-AC converters DC-DC converters* General-purpose switching regulators* Pulse motor drivers 				
		Power application	 Humidifiers, cleaners and other ultrasonic applications* High-frequency heaters* 				
	Power oscillation	High voltage application	 Lighting equipment and other high frequency, high efficiency applications Dischargers, air cleaners* 				
Э	High-speed switching		 Laser pulsers Modulators and drivers in high power transmitter circuits for optical communication Bubble memory drivers 				
	Other		• Series regulators				

* Explained in detail in the following section.

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8. Designing Application Circuits

8.1 Audio Power Amplifiers

Basic design philosophy

Frequency characteristics (frequency vs. gain, phase)

The output stage of an ordinary power amplifier uses a push-pull emitter follower (source follower). This method is popular because it provides a wider transfer bandwidth and more stable operation than other grounding systems.

Meanwhile, the forward transconductance (forward transfer admittance) y_{fs} of power MOS FETs is as large as 1.0 S (siemens). Yet it is only a fraction of that of general bipolar transistors and this represents a disadvantage in terms of open loop distortion. The reason is that when bipolar transistors are used as an emitter follower, y_{fs} is given as:

$$\int y_{fs} = 1/r_e = \frac{I_E}{KT/q}$$

where r_{μ} = Emitter equivalent resistance

K = Boltzmann constant

T = Absolute temperature

q = Electron charge

 $I_{\mathbf{F}} = \text{Emitter bias current}$

 R_L = Load resistance

Even when I_F is 1 A, for instance, $y_{fs} = 40$ S.

Now the relationship between input and output is

$$\mathbf{e_0}/\mathbf{e_i} = \frac{\mathbf{R_L}}{\mathbf{R_L} + 1/\mathbf{y_{fs}}}$$

and the nonlinier component of y_{fs} causes distortion, so that a larger y_{fs} is of greater advantage. In other words, there a power MOS FET has a distortion about 20 dB larger a bipolar transistor, it is necessary to use a larger open loop gain and a larger negative feedback than a bipolar transistor. As shown by the frequency characteristics in Fig. 3-4, however, a Darlingoton connection must be used for bipolar transistors in order to enlarge the bandwidth, so that the two-stage emitter follower would worsen the phase characteristics. In applying a negative feedback, a large phase shift would force a sacrifice of gain frequency characteristics in a phase compensation circuit and the like. Thus, with a source follower with a single power MOS FET, much feedback can be applied over a large bandwidth, and distortion can be reduced.

The driver stage of a power MOS FET does not require a conventional class B driver stage. Therefore, the poles in the amplifier system can be reduced \bigcirc a stable negative feedback amplifier can be formed.

In the frequency characteristics of open loop gain, setting the peak value near $10 \sim 20$ kHz is the key 16 HITACHI to forming a good circuit.

Setting the peak value at the upper limit of the audible range is impossible with conventional bipolar transistors. This can be realized only by using power MOS FETs with excellent high-frequency and switching characteristics.

Fig. 8-1 shows the difference in open loop gain of audio amplifiers designed with power MOS FETs and bipolar transistors.





Consideration for parastic oscillation

As power MOS FETs have excellent high-frequency characteristics, they are liable to cause oscillation when used in high-gain designs such as described in the preceding section. To avoid this, a gate resistance (200 ~ 500 Ω) may be used to prevent a real part of the input impedance to be negative. Or the gate wiring pattern may be minimized (within 5 cm), as stated in the section on precautions in fabrication later in this manual. Or one-point grounding may be used.

When a gate resistance is inserted, frequency characteristics are worsened as shown in Fig. 8-2, so that optimum values must be selected in designing. The gate resistance will have no effect in case the former stage has a high impedance as in a class A driver stage.



Fig.8-2 Frequency Characteristics of Source Follower (Calculated Value)

(2) Typical design - 1 (100 W output at 100 kHz, 0.01%)

A circuit is shown in Fig. 8-3. Design of each . amplifier stage will be discussed below.



Fig.8-3 Full Circuit of 100 W Output Audio Amplifier

• Design of output stage

5. 8-4 shows an equivalent circuit of the output stage for N channel MOS FETs. Ron is a drain-to-source equivalent resistance when the power MOS FET is on. The resistance 1.71 Ω contains some margin as it was calculated for the worst case from the specifications for 2SK135 and 2SJ50.

$$R_{ON} = \frac{V_{DS(sat)}}{I_D} = \frac{12}{7} = 1.71 \ (\Omega)$$

Peak current I_p flowing in load $R_L = 8 \Omega$ at $P_O = 100$ W is calculated from mean current L,

$$P_{O} = I^{2} \cdot R_{L} , I_{p} = \sqrt{2} \cdot I,$$

as $I_{p} = \sqrt{2} \cdot \sqrt{\frac{P_{O}}{R_{L}}} = \sqrt{2} \cdot \sqrt{\frac{100}{8}} = 5 \text{ A}.$

Therefore, if transformer regulation is estimated as 20% and AC line regulation as $\pm 15\%$, then power supply voltage V_{DD} is given as

supply voltage V_{DD} is given as $V_{DD} = 1.2 \times 1.15 \{R_L + 0.5 (R_{ON} + R_S)\} \times I_p = 61.8V.$ In Fig. 8-3, the voltage is set at ±65 V including a margin.



Fig.8-4 Equivalent Circuit of the Output Stage for N-Channel Power MOS FETs

Besigning Application Circuits-

Design of voltage amplifier stage

A power MOS FET can be used with a low driving power. Fundamentally, only the power for charging and discharging the gate-to-source capacitance is needed to

e output stage, so that no class B driver stage is required.

The driving power varies with input frequency. At 100 W output and 10 kHz frequency, it would be about 10 mW.

Therefore, an output stage power MOS FET can be driven directly from a class A predriver (voltage amplifier stage) used in a bipolar transistor amplifier. By eliminating the class B driver, the number of components can be reduced, and impairing the amplifier's performance caused by the driver itself can be avoided. Further, the number of poles for transfer function (open loop gain vs. frequency characteristics) decrease, and the stagger can easily be increased.

sequently, the stability against oscillation is improved.

Transistors for the voltage amplifier stage are required to have a high voltage durability, low C_{ob} , and high f_T . Here the 2SD756A/2SB716A developed especially for power MOS FETs are used. With the⁻ NPN differential amplifier and PNP constant current load, high gain and low distortion characteristics were obtained.

The class A stage bias current is set as 10 mA. When bias current is lacking, sufficient power to drive a power MOS FET at high frequency cannot be supplied, and distortion would worsen.

The drain current temperature coefficient of a power MOS FET undergoes a reversal of polarity at around $I_D =$ 100 mA and temperature compensation in the large current region will be unnecessary. Hence, the bias circuit for a power MOS FET is vastly simplified because only one fixed resistor (1 k Ω) for setting idling current will suffice.

Design of input stage circuit

For the input stage, a stable differential amplifier circuit was formed by using the high-voltage, low-noise transistor 2SA872, which is known for its high performance in improving the S/N ratio. Bias current is set as 0.5 mA.

• Typical characteristics of experimental circuit (Fig. 8-3)

Output vs. distortion characteristics are shown in Fig. 8-5. At f = 1 kHz, total harmonic distortion (THD) is approximately 0.002%, which is the limit value for any measuring system available on the market today.

Through optimum design, the following can be obtained at rated output:

$f = DC \sim 100 \text{ kHz},$ THD $\leq 0.01\%$

Thus, characteristics that cannot be obtained with conventional bipolar transistors are realized with power MOS FETs.



Fig.8-5 Total Harmonic Distortion VS. Output Characteristics

Precautions in fabrication

- Minimize the gate wiring, although its relationship with gate resistance must be taken into consideration.
- Provide one-point grounding for the amplifier base plate, power supply, chemical fapacitor to prevent ± line unbalance, and speaker terminals.
- The output coupling coil has the effect of reducing distortion in the high frequency range, and preventing abnormal oscillation in capacitance loaded operation. But the values should be determined while experimenting.

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8. Designing Application Circuits

(3) Typical design - 2 (50 W output at 50 kHz, 0.01%)
 Introduced here is a power amplifier with a rated output
 W and which attains a total harmonic distortion of
 0.01% over the entire frequency bandwidth of from 5 Hz to
 50 kHz. The basic design method has been introduced in
 the previous section. The output stage, as shown in Fig. 8-6,
 is of the single push-pull construction. Considering the
 power supply voltage and transformer regulation, the
 complementary pair 2SK133/2SJ48 would suffice as the

This circuit can produce an output of about 70 W by

improving transformer regulation or stabilizing the power supply line.

In the frequency characteristics of open loop gain, the peak point is set at 10 kHz, 100 dB. Even at 100 kHz, a high gain of 85 dB is ensured.

Fig. 8-7 shows the distortion vs. output characteristics with the experimental circuit.

In this high negative feedback amplifier, caution must be taken to avoid the oscillation which depends on the printed pattern.







8. Designing Application Circuits-

Fig. 8-8 shows the standard printed pattern. The amplifier devices that drive the output stage power MOS TETs consist only of five small-signal transistors, so that the printed board is extremely small.

Wiring between the voltage amplifier stage collector and the power MOS FET gate must be minimized. The arrangement and configuration of the printed board and the heat sink must be selected carefully.

Characteristics



Fig.8-8 Standard Printed Pattern in Actual Size

In Fig. 8-8 which shows the example of the printed board pattern, the printed board is attached directly to the heat sink to minimize the gate wiring.

(4) Recommended line-up by output power

Line-up of devices in audio amplifiers of different outputs is shown Table 8-1.

Output	Ілри	t Stage	Drive	Driver Stage		Output Stage					
Power (W)	N-Channel	P-Channel	N-Channel	P-Channel	Con-	то)-3	HP	AK	VDEV	
	(NPN)	(PNP)	(NPN)	(PNP)	nection	N-Channel	P-channel	N-Channel	P-Channel		
	2SK151 (TO- 92MOD.)	2SJ51 (TO- 92MOD.)	2SK213 (TO- 220AB)	2SJ76 (TO- 220AB)							
50~			2SD756 (TO- 92MOD.)	2SB716 (TO- 92MOD.)		2SK133	2SJ48	2SK225	2SJ81	120	
80	2SC1775 (TO-92)	1775 -92) 2SA872 (TO-92) 2SD756A 2SB716A (TO- 92MOD.) 92MOD.) 2SK214 2SJ77 (TO- 2ZOAB) 220AB) Single Push-Pull 2SK134									
			25K214 (TO- 220AB)	2SJ77 (TO- 220AB)	Push-Pull	25K134	2SJ49	2SK226	2SJ82	140	
			2SD758 (TO-202AA MOD.)	2SB718 (TO-202AA MOD.)		264176		•	-		
		-	2SK216 (TO- 220AB)	2SJ79 (TO- 220AB)	-	258175	25J55			180	
100~	2SC1775	2SA872	2SD666A (TO- 92MOD.)	2SB646A (TO- 92MOD')		201124	2SJ49		2SJ82		
140)	(TO-92)	(TO-92)	2SK214 (TO- 220AB)	2SJ77 (TO- 220AB)		25K134		25 K 226		140	
-			2SD668A (TO- 126MOD.)	2SB648A (TO- 126MOD.)	Parailei Push-Puli	202126			2SJ83		
			2SK215 (TO- 220AB)	2SJ78 (TO- 220AB)		25K135	2SJ50	2SK227		160	
150~ 200	2SC1775A (TO-92)	2SA872A (TO-92)	2SD758 (TO-202AA MOD.)	2SB718 (TO-202AA MOD.)	ſ	2SK176	2SJ56	_		200	

able 8-1 Line-up of Devices in Audio Power Amplifier

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8. Designing Application Circuits

8.2 Power Oscillators (I)

Power MOS FETs have excellent high frequency characteristics and their operating frequency extends to the 10 MHz band and higher. Taking advantage of their high switching speed and ease of biasing, one can use them for economical high-frequency power sources as in such new application as high-frequency heating and high voltage generation.

Power MOS FETs require a far lower driving power than bipolar transistors do, and can be parallel-operated easily, providing the required large output. Basic design procedures for an oscillation circuit and practical applications will be described below.

(1) Basic design of power oscillation circuit

Operation in a high frequency circuit is affected by light capacitances of the devices and parts used. Also, depending on the DC bias circuit arrangement and ground points, feedback quantity varies and affects the characteristics. Therefore, a circuit configuration determined through calculations must be modified in the process on construction. Described below are the basic principles that provide design guidelines for high frequency FET oscillation circuits.

In Fig. 8-9, (a) is a basic oscillation circuit, and (b) an equivalent circuit. Z_1 , Z_2 and Z form a tank circuit. By using the same type of reactance for Z_1 and Z_2 , positive feedback can be applied. The signal applied to the gate is amplified at the drain with a 180° phase differential and current of the same phase flows in reactances Z_1 and Z_2 , so that it will have a 180° phase differential against the source current. As a result the amplified signal at the gate is positively fed back.

When power MOS FETs are used in a Colpitts oscillalon circuit with Z_1 and Z_2 as capacitances, operation at high frequency becomes possible.

Limitation for high frequency operation is created by losses expressed by electrode capacitance C_{gs} and series gate resistance R_g in Fig. 8-9. The voltage applied to the gate is divided between R_g and C_{gs} , and reduces g_m at high frequency. At the same time, phase delay is caused.

The frequency at which g_m decreases by about 3 dB is, in the case of 2SK135:

$$f_{(3dB)} = \frac{1}{2\pi \cdot R_g \cdot C_g}$$

$$\approx 3 \text{ MHz}$$







Oscillating conditions

Since power MOS FETs have a large g_m and power gain, an oscillator can be formed even at frequencies higher than $f_{(3dB)}$.

Next, oscillating conditions will be sought for Fig. 8-9 (b).

When gate current is denoted by i_1 , drain current by i_2 , and tank circuit current including load by i_3 , the following equation holds for the loop current:

Equation (1) has finite solutions other than $i_1=i_2=i_3=0$. In other words, in order that the circuit may oscillate, it is necessary that the value of the determinant consisting of constants be zero, as follows:

In an area of operation where drain current i_2 is not dependent on drain voltage but rather on gate voltage, R_0 is far larger than the other parameters and the following equation holds:

$$jZ_2 \cdot X_g \cdot g_m + Z_1$$

- $(Z_2 + Z + Z_1) \frac{Z_1 + Z_g}{Z_1} = 0$ (3)

aginary part is: ΤŀĘ

> $R_2 \cdot X_1 \cdot X_g \cdot g_m - (R_2 + R) R_g$ + $(X_2 - X)(X_1 + X_g) + X_1 \cdot X_g = 0$ (4)

If the terms with load resistances R₂ and R of the oscillator are neglected, then frequency would be determined by the following equation:

$$\mathbf{X} = \frac{\mathbf{X}_1 \cdot \mathbf{X}_g}{\mathbf{X}_1 + \mathbf{X}_g} + \mathbf{X}_2 \quad \dots \qquad (5)$$

Thus.

$$(2\pi f)^2 = \omega^2 = \frac{1}{L} \left(\frac{1}{C_1 + C_g} + \frac{1}{C_2} \right) \qquad (6)$$

Next, from the real part, we get:

$$X_{2} \cdot X_{g} \cdot gm - (R_{2} + R) \frac{X_{1} + X_{g}}{X_{1}}$$

$$(X_{2} - X + X_{1}) \frac{Rg}{X_{1}} = 0 \qquad (7)$$

$$gm - \frac{(R_{2} + R)}{X_{2}^{2}} \cdot \frac{X_{2}}{X_{1} \cdot X_{g}/(X_{1} + X_{g})}$$

$$- \frac{Rg}{Xg^{2}} \cdot \frac{X_{1} \cdot X_{g}}{X_{1} + X_{g}} \cdot \frac{1}{X_{2}} = 0 \qquad (8)$$

From Equation (8), since g_m must be large enough to compensate for circuit loss, the following oscillation start con Tons are obtained:

$$gm \ge \frac{C_2}{C_g + C_1} \cdot Gin + \frac{C_g + C_1}{C_2} \cdot G_L \quad \dots \qquad (9)$$

Where G_{in} and G_L are loss conductances of input and output circuits respectively.

Gin $\geq \frac{Rg}{Xg^3}$, $G_L \geq \frac{R_2 + R}{X_2^2}$

In the case of high-efficiency power oscillators, the term on the right side of Equation (9) represents an seci imp nt loss term, and g_m is expressed with gate voltage V_{g} , output voltage V_{out} , and output power P_{out} , as follows:

$$gm \ge \frac{Vout}{Vg} \cdot G_L = \frac{2 \cdot Pout}{Vg \cdot Vout}$$
 (10)

DC bias conditions and AC amplitude

Let us consider the relationship between DC bias conditions and AC amplitude in the various operating modes of the power oscillator in Fig. 8-10.

At conductor angle θ , the various current and voltage parameters of the device are as shown in Fig. 8.11. Drain current is:

$$U_{D} = I_{A} (\cos \omega t - \cos \varphi) \qquad (11)$$

Basic wave amplitude:

$$I = \frac{2}{\pi} \cdot \int_{0}^{\varphi} i_{D} \cos \omega t d (\omega t)$$
$$= I_{A} \cdot \frac{\varphi - \sin\varphi \cdot \cos\varphi}{\pi} \qquad (12)$$

Mean current:

$$I_{O} = \frac{1}{\pi} \cdot \int_{0}^{\varphi} i_{D} d(\omega t)$$
$$= I_{A} \cdot \frac{\sin \varphi - \varphi \cos \varphi}{\pi} \qquad (13)$$

The relationship with peak current: $I_p = I_A (1 - \cos \varphi)$

$$I = I_p \cdot \frac{\varphi - \sin\varphi \cdot \cos\varphi}{\pi(1 - \cos\varphi)} \quad \dots \qquad (14)$$

$$I_{O} = I_{P} \cdot \frac{\sin\varphi - \varphi \cos\varphi}{\pi(1 - \cos\varphi)} \quad \tag{15}$$









The ratio of maximum power against supplied DC power, viz., drain efficiency, is expressed as follows, where current and voltage efficiencies are denoted by η_i and η_e respectively:

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8. Designing Application Circuits -

 η_e can be calculated similarly.

The relationship between conduction angle θ and η_i is given as in Fig. 8-12.

Next, the bias conditions that determine conduction angle $\theta = 2\varphi$ will be sought.

If peak gate voltage is denoted by V_{GP} then: $V_{GP} = V_{GO} + V_{GA} - R_3 \cdot I_0$ (17) where $V_{GO} = V_O \cdot \frac{R_2}{R_1 + R_2}$: Initial bias voltage to gate

V_{GA}: Gate amplitude I_O: Drain mean current





Fig.8-12 Current Efficiency VS. Conduction Angle

If the gate voltage satisfying the conditions for oscillation start is

$V_{GST} = V_{GO} - R_3 \cdot I_{ST}$		(18)
hen, from Fig. 8-11, we get	•	
V	. 7	

 $V_{GA} \cdot \cos \varphi = R_3 \cdot I_O - V_{GO}$ (19) From Equations (17), (18), (19), we get:

$$3 = \frac{V_{GST} + \frac{\cos\varphi}{1 - \cos\varphi} \cdot V_{GP}}{L_0 - L_{GT}}$$
(20)

$$\mathbf{V}_{GO} = \mathbf{V}_{GST} + \mathbf{R}_3 \cdot \mathbf{I}_{ST}$$
(21)
$$\mathbf{V}_{GA} = \frac{\mathbf{V}_{GP}}{\mathbf{V}_{GP}}$$
(22)

Determination of circuit parameters

 $1 - \cos a$

Circuit parameters and maximum ratings of devices for an FET oscillator will be considered. For high-efficiency operation, drain bias voltage must be maximized. Let us make it one-half the allowable voltage V_{DSX} max. of the device.

 $V_0 = \frac{1}{2} V_{DSmax}$ (23)

From the relationship between allowable drain loss and mean voltage, we get the drain mean current as follows:

$$I_0 = \frac{D}{V_0}$$
 (24)

Equation (24) represents a condition where allowable loss is not exceeded even at oscillation stop. 24 HITACHI The peak current for class B operation is obtained from Equation (15) as follows:

 $I_{p} = \pi \cdot I_{O} \qquad (25)$

Gate peak voltage V_{GP} can be determined as a value corresponding to I_p in Equation (25) from the $I_D - V_{DS}$ characteristics of power MOS FETs (see Figs. 3-1 and 3-2 in Chapter 3). As for oscillation starting current I_{st} , from the conditions of Equation (10), denoting drain voltage amplitude by V, the following is determined:

$$gm > \frac{2 \cdot Pout}{Vg \cdot V} = \frac{2 \cdot I_0 \cdot \eta_p}{Vg} \qquad (26)$$

For safety's sake, the value of oscillation start current is determined from the $g_m \cdot I_D$ characteristics of power MOS FETs (see Fig. 8-13) as the value of I_{st} corresponding to twice the value of Equation (26). From these data and Equations (20), (21) and (22), the bias parameters of V_{GO} and V_{GA} can be determined.





Example of parameter calculation

By applying the above method to 2SK135, the following calculated results are obtained:

 $V_{O} = 70 \quad (V)$ $I_{O} = 1.43 \quad (A)$ $I_{p} = 4.5 \quad (A)$ $V_{Gp} = 6 \quad (V)$ $g_{m} = 2 \times 0.374 \quad (S)$ $I_{st} = 0.6 \quad (A)$ $V_{GO} = 2.9 \quad (V)$ $V_{GA} = V_{GP} = 6 \quad (V)$

Calculation of resonator capacitance

In order to set the divided voltages of gate voltage V_g (= V_{GA}) and drain voltage V_D to meet the above operating conditions, resonator capacitances C_1 and C_2 will be determined.

With regard to drive voltage drop due to Rg, the following equation holds:





$\frac{Vg}{V_D} = \frac{Cds + C_2}{Cgs + C_1} \cdot \frac{1}{\sqrt{1 + (\frac{\omega}{\omega_0})^2}} \dots (27)$ where $\omega_0 = \frac{1}{Rg \cdot Cgs}$

And the values of capacitance pair C_1 and C_2 are determined. Coil inductance for the desired frequency can be derived from these capacitance values.

The value of load Q can be increased by using a Clappe type oscillator in which a capacitance is provided in parallel between the gate and drain or inserted in series with the inductance.

The load is expressed as follows, using output voltage V_{out} and circuit efficiency η_c .

The specified output can be obtained by giving a re- sance or output voltage satisfying Equation (28).

Ais oscillator gives the maximum output at optimum lo out no destruction of devices occurs even under overload. In other words, gate driving voltage is proportional to drain voltage and, under light load, drain voltage does not exceed bias voltage. Under heavy load, drain voltage amplitude decreases and the power MOS FET is protected. (2) Experimental circuit and typical characteristics (13.5)

MHz, 40 W)

when the constants are determined in accordance with the asic design procedure described in item (1) above, the circuit shown in Fig. 8-15 is obtained. The circuit configuration is extremely simplified and can be applied to circuits that give the desired frequency and output power.

Fig. 8-16 shows the supply voltage dependency of major characteristics. An outstanding feature is that highefficiency oscillation is obtained because circuit efficiency does not change with supply voltage or output power.





Designing Application Circuits



8.3 Power Oscillators (II) (DC-DC Inverter)

The inverter described here introduces the basic theory of the Colpitts oscillator referred to above in order to obtain high frequency and high power, so that it can be applied to high-frequency, high-efficiency lighting equipment, dischargers, and air cleaners. Important performance requirements for inverters and converters are as follows:

- High power efficiency (small circuit losses).
- Large area of safe operation for power devices and minimal temperature rises for equipment.
- Low spike noise at switching of power devices and stable output.
- Little unnecessary radiation from equipment.
- Small weight and volume of equipment.

The above requirements vary in importance depending on the system in which inverters and converters are used. But indispensable performances of power devices are exactly those which Hitachi's power MOS FETs feature, namely:

- High switching speed.
- Simple driving circuit; large power gain so that driving power may be minimized.
- Large current handling capability in the area of safe operation, particularly in the high voltage area (secondary breakdown region), because these devices are used at high voltage.
- Typical design

With $400 \sim 500$ V output voltage and 400 kHz frequency as the target specifications for the inverter, circuit constants will be determined.

For deriving output, a capacitor loaded in the middle of the oscillator loop will be used. Output current will thus be obtained by discharge of electrons accumulated in the capacitor.

First the basic circuit is set as in Fig. 8-17, where C_L denotes a load capacitor, R_1 and R_2 are bias resistances of gate, and V_i stands for unstabilized input voltage (which gives V_C and V_D).

Fig. 8-18 plots output voltage and frequency with C_1 as parameter under the conditions of $C_1'=\infty$,

 $C_2 = 0.05\mu$ F, L = 0.0384mH, $C_S = 5$ pF, $R_E = 2\Omega$, $C_E = 0.1\mu$ F, $C_L = 0$ pen, $R_2 = 70$ k Ω , $V_i = 45$ V.

The figure shows that output voltage is dependent on the C_1 value and there is an optimum output voltage. Oscillation frequency also varies with C_1 and shows a tendency of monotone increase and decrease.

Next, characteristics measured with input voltage Vi as parameter are shown in Fig. 8-19. The measurement conditions are $C_1' = \infty$, $C_2 = 0.05 \,\mu$ F, $C_S = 5 \,\mu$ F, $\mathbf{R}_{\mathbf{E}} = 2\Omega, \mathbf{C}_{\mathbf{E}} = 0.1 \mu \mathbf{F}, \mathbf{C}_{\mathbf{L}} = \mathbf{Open}, \mathbf{R}_{2} = 70 \text{ k}\Omega.$

Fig. 8-19 shows that the desired output voltage is dependent on input V_i and can be selected at will and that frequency variation can be reduced. Frequency drift during operation is due to heat generation in the capacitor. For practical purposes, a low-loss capacitor with a small temperature coefficient (e.g., mica, polypropylene) must be used.

The inverter introduced above involves a relatively small power. But a similar principle applies to high-voltage power supplies that require higher frequencies and higher voltages.







8.4 Medium-Wave Transmitters (Based on data of NHK Technical Research Laboratories)

Solid state devices are being used increasingly nowadays in medium-wave transmitters. However, no optimum power constructions are available for use in power amplifier circuits and not a few problems involving circuit performance remain to be resolved. A high-efficiency, high-power pulse amplifier using power MOS FETs will be described.

Generally, in pulse amplification, power MOS FETs have many advantages over bipolar transistors, as follows:

• Pulse width does not change because of the absence of carrier storage effect.

Drain current has a negative temperature coefficient,

- so that no thermal runaway or current hogging occurs; as a result, stable operation is ensured.
- They have a large input resistance; since they are enhancement type devices, input and output terminals are isolated and the bias circuit is simplified compared with other field effect transistors.

A small driving power suffices; driver and input

power amplifier circuits are simplified.

- The desired output is obtained easily by parallel operation.
- Design, adjustment and operation are simple.

A class D SEPP pulse amplifier with 1 kW CW at $0.5 \sim 1.5$ MHz carrier frequency and $80 \sim 90\%$ overall efficiency will be described. A class D type is selected because a final power amplifier efficiency of 90% or better can be expected theoretically.

(1) Class D SEPP type pulse emplifier

Fig. 8-20 is a block diagram of the power amplifier.

In the carrier generator, radio frequency is pulse-widthmodulated by the audio frequency signal. Here, pulsewidth-modulated wave is generated according to the twovalued logic, and is drawn out as two-phase pulse and applied to the driver stage.

The input parts of the power amplifier are transformer coupled. Amplitude modulation wave is mixed and filtered in the output tank circuit and applied to the load (antenna).



8. Designing Application Circuits-

Power amplifier circuit

Fig. 8-21 shows a power amplifier circuit. A total of 16 power MOS FETs are used, four each in parallel.

In the SEPP system, since the source electrodes of power supply side MOS FETs Q_1 and Q_1' are connected to the output transformer, an AC coupling system with capacitors and resistors cannot be used. A transformer coupling as shown in Fig. 8-21 is required.

The primary and secondary winding ratio of the input transformer is 1 : 1 (5 turns each) and bifiler winding is used. An E type core is used, but output characteristics vary considerably with the kind of core.

A clock pulse of 140 $V_{P,P}$, which is the maximum rated voltage for this device, is applied to the gate of the PA stage power MOS FET.

Fig. 8-22 shows theoretical waveforms at different points in Fig. 8-21. Since only carrier signals are used in this asse, only the unmodulated carrier component is obtained at the output terminal.

When a pulse-width-modulated wave is applied as a clock pulse to the MOS FET gate, a two-valued PWM wave (1 level: V_{PA} , -1 level: $-V_{PA}$) that has undergone pulsewidth modulation with audio frequency is obtained at the output transformer secondary. This PWM wave is filtered in the series resonance circuit consisting of a choke coil and capacitor, and the basic component is derived. Since the crest value of waveform of this basic component varies with pulse width, only the amplitude modulated wave is derived at the output terminal.







Fig.8-21 PA Circuit in SEPP System

Output variation by transformer winding ratio

Figs. 8-23 through 8-25 show the dependence of output "yer and power amplifier efficiency on PA supply voltage at different winding ratios. Fig. 8-26 plots the relationship between PA efficiency and output power with winding ratio as the variable.

While no reference will be made here to transformer types (e.g., core shape, bobbin shape), it has been verified experimentally that use of an E type core and a flat bobbin is effective in achieving high efficiency.







The characteristics shown in Fig. 8-23 through 8-25 are the result of optimum selection based on these tendencies.

From these experiments, it is found that an efficiency of $80 \sim 90\%$ can be expected at PA power supply voltages of $0 \sim 140$ V, if the output transformer primary vs. secondary winding ratio is selected at below 1 : 4. Particularly at a winding ratio of 1 : 2, stable operation was obtained at 1.3 kW output power (1 MHz continuous wave) and 87% efficiency.



Fig.8-24 Output Power vs. PA Supply Voltage for Various winding Ratio of Transformer



Various Winding Ratio of Transformer

8. Designing Application Circuits

[Reference Data]

No.	Winding Ratio	Bobbin	Core
F1	Primary:Secondary = 1:2(Primary:8 Turns, Parallel in 5(Secondary:16 Turns, Parallel in 2Material:Enamel wire ϕ 2mm	Material: Teflon Refer to Fig. 8-27	Insert H6ER-type Ferrite
F2	Primary : Secondary = 1:4 (Primary : 3 Turns, Parallel in 4 (Secondary : 12 Turns, Parallel in 2) Material : Enamel wire ϕ 2 mm	_	E-Core Refer to Fig. 8-28(2)
F3	Primary:Secondary = 1:6(Primary:2 Turns, Parallel in 4Secondary:12 Turns, Parallel in 2Material:Enamel wire ϕ 2 mm	-	E-Core Refer to Fig. 8-28(a)
F4	Primary:Secondary = 1:2(Primary:2 Turns, Parallel in 4Secondary:4 Turns, Parallel in 2Material:Enamel wire ϕ 2 mm	-	E-Core Refer to Fig. 8-28(b)
FS	Primary : Secondary = 1:3 (Primary : 2 Turns, Parallel in 4 (Secondary : 6 Turns, Parallel in 1) Material : Enamel wire ϕ 2 mm		E-Core Refer to Fig. 8-28(b)





Fig.8-27 Bobbin Shape





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8.5 High Power Switching Regulators Using Direct Rectification System

Design of a 500 W class switching regulator using power MOS FETs will be introduced. Described below are the features of power MOS FETs as switching devices, followed by calculation of ideal characteristics, design procedure, and measured values.

(1) Advantage of power MOS FETs

Power MOS FETs are capable of high-speed switching, so that the driving circuit is simplified even for frequencies as high as several hundred kHz. Also, when a variable duty ratio control system is used, carrier storage time of the power MOS FET can be neglected, and a wide control range is ensured.

Therefore, output well follows input ripples, and a small filter capacity suffices. This contributes much to improving ator performance.

ext, switching frequency can be raised to the limit, which is dependent on the performance of the high-speed rectifier diode. Therefore, efficiency can be augmented, equipment can be made compact, and safety improved compared with transistor converters.

(2) Calculation of ideal characteristics

Fig. 8-29 shows a theoretical circuit for a switching regulator. When it is assumed that capacity C is sufficiently I_{O} output E_{O} is constant, and both switch S and coil L have no loss, then, from the current waveform of Fig. 9-30, the following equilibrium equation holds:









At switch on:

$L \frac{dI_L}{dt} = E - E_O$	(1)
$\therefore I_{L} = \frac{E - E_{O}}{L} \cdot t + I_{O}$	(2)

At switch off:

$$L \cdot \frac{dI_L}{dt} = -(E_O + V_D)$$
 (4)

$$\therefore I_{L} = -\frac{E_{O} + V_{D}}{L} \cdot t + I_{1} \quad \dots \qquad (5)$$

$$I_0 = I_1 - \frac{E_0 + V_D}{L} \cdot T_2$$
 (6)

Thus,
$$(E - E_0)I_1 = (E_0 + V_D)I_2$$

Therefore, $E_0 = E \cdot \frac{T_1}{T} - V_D \cdot \frac{T_2}{T}$ where $T = T_1 + T_2 \cdots (7)$

Mean load current IR will be:

$$I_{R} = \frac{I_{1} + I_{0}}{2}$$
 (8)

Next, if I_0 , I_1 is denoted by I_R , then

$$I_{1} = I_{R} + \frac{E - E_{O}}{2 \cdot L} \cdot T_{1}$$
(9)
$$I_{0} = I_{R} - \frac{E - E_{O}}{2 \cdot L} \cdot T_{1}$$
(10)

Since minimum load current I_0 is larger than 0, from Equation (10), the minimum value for coil L will be:

$$L_{\min} = \frac{E - E_0}{2I_R} \cdot T_1 \quad \dots \qquad (11)$$

If the variation value of load current is put as $\Delta I = I_1 - I_0$, then, from Equations (9) and (10), we get

$$\Delta I = \frac{E - E_0}{L} \cdot T_1$$
 (12)

If variation ratio is put as $\alpha = \Delta I/I_R$, then the required L value is determined as

To seek conduction angle T_1/T , from Equation (7), we get

$$\mathbf{E_0} = \mathbf{E} \cdot \frac{\mathbf{T_1}}{\mathbf{T}} - \mathbf{V_D} \left(1 - \frac{\mathbf{T_1}}{\mathbf{T}}\right)$$

8. Designing Application Circuits

Therefore,

$$\frac{T_1}{T} = \frac{E_0 + V_D}{E + V_D} \qquad (14)$$
Next, let us seek the values of power and efficiency.
Input power $W_1 = \frac{E}{T} \int_0^{T_1} \left(\frac{E - E_0}{L} \cdot t + I_0 \right) dt$

$$= \frac{E}{T} \left(\frac{E - E_0}{2L} \cdot T_1^2 + I_0 \cdot T_1 \right)$$
Substituting Equations (9) and (10) into this, we get
 $W_1 = \frac{T_1}{T} \cdot E \left(\frac{I_1 - I_0}{2} + I_0 \right)$

$$= \frac{T_1}{T} \cdot E \cdot I_R = E \cdot \frac{E_0 + V_0}{E + V_D} \cdot I_R \qquad (15)$$
Output power
 $W_0 = E_0 \cdot I_R \qquad (16)$
Output efficiency
() $\eta = \frac{W_0}{W_1} = \frac{E_0}{E} \cdot \frac{E + V_D}{E_0 + V_D} \qquad (17)$
Power loss W_D of the rectifier diode is given as:
 $W_D = V_D \cdot \frac{1}{T} \int_0^{T_2} \left(I_1 - \frac{E_0 + V_D}{L} + T_2^2 \right)$

$$= \frac{V_D}{T} (I_1 \cdot T_2 - \frac{E_0 + V_D}{2L} \cdot T_2^2) = V_D \cdot I_R \cdot \frac{T_2}{T}$$

$$= V_D \cdot \frac{E - E_0}{E + V_D} \cdot I_R \qquad (18)$$
Thus, $W_1 = W_L + W_D = (E_0 + V_D \cdot \frac{E - E_0}{E + V_D}) I_R$

$$= E \cdot \frac{E_0 + V_D}{E + V_D} \cdot I_R \qquad (19)$$

 $V_D = 1V$, $I_R = 4A$, f = 80 kHz (T = 12.5 μ s), then T₁ Зия.

When $\alpha = 0.5$, then $L = \frac{E - E_0}{0.5 I_B} \cdot T_1 = 157 \,\mu\text{H}$, #= 0.99 (99% efficiency)

Efficiency increases as input, output voltage ratio E_o/E approaches 1.0. In designing an actual switching regulator, losses and optimum values must be calculated individually for the main power supply, switching circuit, control circuit, and filter circuit.





(3) Typical design

Basic design philosophy

Maximum output 500 W

Variable voltage range $10 \sim 100 \text{ V}$

- Input power 500 W
- Input voltage
- Type of circuit
- Switching frequency

40 kHz (25 μs) Rectifier diodes currently available have a reverse breakdown voltage of 300 V, a maximum current of 6 A, a reverse recovery time of 0.2 µs, and a forward voltage of 0.8 V or so. If these performance figures are improved, switching can be performed at higher frequencies.

Input part is a 100 V AC direct bridge rectification system; power MOS FETs are driven by capacitance-coupling and controlled by variable duty type

The sensing output voltage feedback loop is isolated by a photo coupler.

140 V

control.

- Output transformer winding ratio and
 - 20:18 in turns; EIH-90.

core

- **Cautions in fabrication**
- Since the output transformer winding is subject to sharp current spikes, it is required to have a large capacity. Vinyl wire is recommended.
- Providing a center tap on the output transformer's secondary winding and using full-wave rectification are effective in reducing rectifier diode loss. (In the example described below, the bridge rectification system is used for both primary and secondary windings.
- A large capacity choke coil should be used in order to maintain a constant current over a wide range.
- Circuit operation

The basic circuit configuration of this regulator is shown in Fig. 8-31.

in the sensing block, the voltage at the output terminal is divided and compared with the reference voltage generated by a Zener diode, and the error voltage is output.

Here, a single operational amplifier IC, HA17741, is used in the error amplification circuit and the overcurrent limitation circuit. The circuit configuration is a standardized one.

In the control block, a variable duty circuit is used to reduce noise.

The power MOS FET has a switching speed as fast as 20 ~ 30 ns and is liable to generate noise. Also, its high input impedance can induce external noise, which in turn can

cause misoperation.

In the variable duty circuit, therefore, rectangular waves which the direct current component is superposed on the or signal are integrated and the voltage comparator is operated at the cross-zero point.

As a result, the loop has a low response speed but is not affected by noise.

The drive block uses the CMOS inverter IC HA14011B which drives the power MOS FETs and a complementarily connected 200 mW class transistor. This block illustrates the characteristic ease of use of power MOS FETs. The driver need only have an input power of 10 V and a charge/discharge capacity of 1,000 pF. The drive circuit is vastly simplified. If it is assumed that the power MOS FET rise time t_r is 30 ns, then, one only has to consider the 300 mA transient current and the approximately 0 mA steady state current (there is a slight leak current).

The circuitry of the blocks described above is presented in Figs. 8-32 through 8-34.

Fig. 8-35 shows a timing chart for the control block.







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8. Designing Application Circuits



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Fig.8-34 Drive Block



8. Designing Application Circuits

Nominal characteristics of experimental circuit

Figs. 8-36 and 8-37 show voltage waveforms, respectively, for the output transformer secondary and differential voltage between choke coil terminals. It will be seen that the conduction angle follows the specified output. Under the operating conditions of 80 V and 3 A, the duty factor is





about 70%. Other characteristics illustrated are the following:

Fig. 8.38 Regulation characteristics

Fig. 8-39 Efficiency vs. output current characteristics (Vo constant

Fig. 8-40Efficiency vs. output voltage characteristics (IO constant Fig. 8-41 Efficiency vs. output current characteristics (PO constant







Fig.8-38 Regulation Characteristics



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8.6 Low-Noise DC-DC Converters

The converter introduced here is based on a design philosophy different from that of the high-power, highefficiency switching regulator described in the preceding chapter.

Spike noise has been reduced to the limit in this converter, so that it can be used in the PCM decoder part of electronic switching systems which are sensitive to noise at the small signal level.

The circuitry and test results are described below.

(1) Circuit configuration and operation

A block diagram is presented in Fig. 8-42. It is a single-transistor converter using a power MOS FET as the main switch. Low noise is achieved by:

• effectively utilizing the electrode structure of power MOS FETs (source electrode is connected to header), and loosely coupling the output transformer.

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For driving and controlling the power MOS FET, a CMOS gate IC is employed.

A 12 V, 5 mA subsidiary power supply is provided by dividing the voltage at the AC input.

The control loops are isolated by means of a photo coupler of 4 MHz bandwidth.

Radiation can be coped with by a shield plate; there is no need for a special noise filter. (When the converter was mounted in a PCM decoder, crosstalk to the adjacent channel was below -90 dBm/20 kHz.)

Since carrier storage effect can be neglected in driving a power MOS FET, a mirror integration circuit is formed with C_2 and the transformer primary, as shown in Fig. 8-42. As a result, the switching waveform draws a gentle slope and the spike component is completely removed.





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Fig.8-43 Drive Circuit for DC-DC Converter

Results of experiment hajor performance figures are shown in Table 8-2. By taking advantage of the performance, circuits that produce the desired output voltage and current can be designed.

. Item	Condition	Performance	
Input Voltage	_	-48±5V	
tput Voltage, Current	Full load	+12V, 1.7A	
Spike Voltage	Full load	4mVp-p	
Regulation for Input Voltage Changes	-48V → -53V	+2mV	
Regulation for Load Changes	Non load → Full load	-17mV	
Efficiency	Full Load Full Circuit	71%	

Table 8-2 Major Performance Figures

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Figs. 8-44 and 8-45 show operation waveforms of the power MOS FET, and Fig. 8-46 the output terminal ripple nd spike noise waveforms.











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